

Electronic Supplementary Information

Tunable preparation of highly dispersed Ni_xMn-LDO catalysts derived from Ni_xMn-LDHs precursors and application in low- temperature NH₃-SCR reaction

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Figure captions

Table S1 Comparison of catalytic performance of different Ni-Mn oxides catalysts.

Fig. S1 SEM image and EDS mapping of Ni₃Mn-LDO catalyst.

Fig. S2 SEM image and EDS mapping of Ni₄Mn-LDO catalyst.

Fig. S3 SEM image and EDS mapping of Ni₅Mn-LDO catalyst.

Fig. S4 SEM image and EDS mapping of Ni₆Mn-LDO catalyst.

Table S1 Comparison of catalytic performance of different Ni-Mn oxides catalysts

Catalysts	Preparation method	Reaction conditions	NO _x conversion/% (Tem./°C)	Ref.
Ni-MnOx	co-precipitation	500 ppm NO, 500 ppm NH ₃ , 5 vol % O ₂ in He, GHVS=64.000 h ⁻¹	80% (100-300 °C)	[1]
NiMn ₂ O ₄	solvothermal	500 ppm NO, 500 ppm NH ₃ , 5 vol % O ₂ in Ar, GHVS=68.000 h ⁻¹	80% (85-250°C)	[2]
Ni-Mn-O-10	low temperature crystal splitting	400 ppm NO, 400 ppm NH ₃ , 2 vol % O ₂ in N ₂ , GHVS=30.000 h ⁻¹	80% (90-270°C)	[3]
Ni-Mn(3DH-NM/NF)	hydrothermal	500 ppm NO, 500 ppm NH ₃ , 3vol % O ₂ in N ₂ , GHVS=20.000 h ⁻¹	80% (250-360°C)	[4]
NiMn-LDO	co-precipitation	500 ppm NO, 500 ppm NH ₃ , 5 vol % O ₂ in He, GHSV=45.000 h ⁻¹	80% (160-390°C)	This work

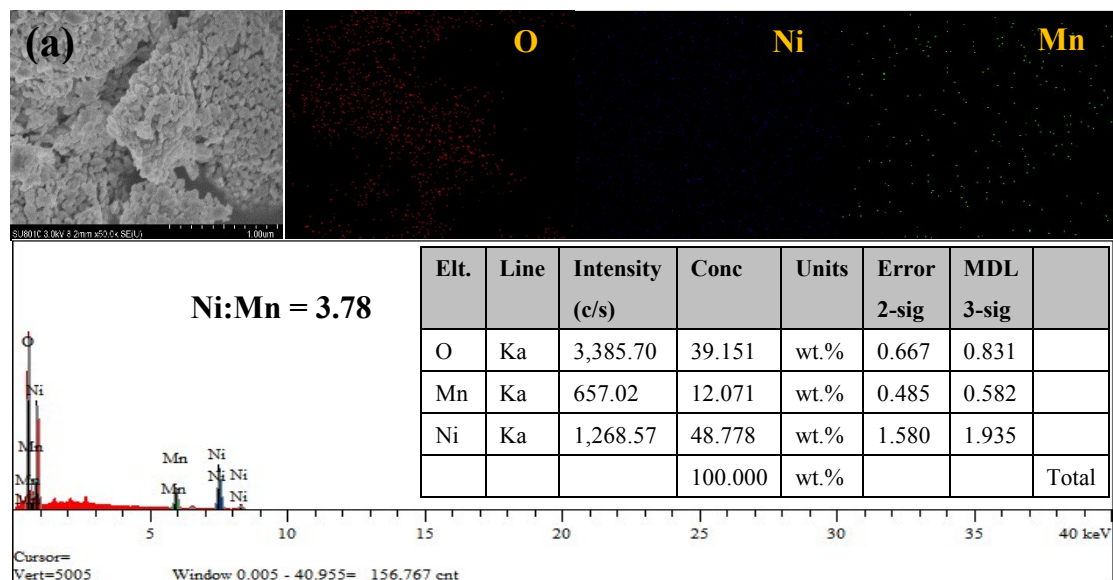


Fig. S1 SEM image and EDS mapping of Ni₃Mn-LDO catalyst.

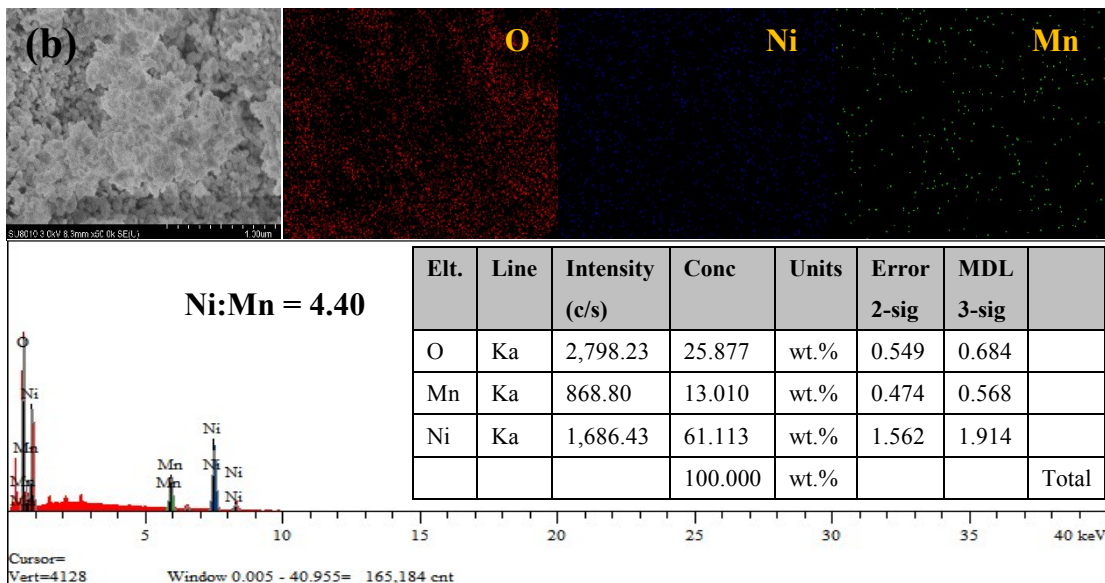


Fig. S2 SEM image and EDS mapping of Ni₄Mn-LDO catalyst.

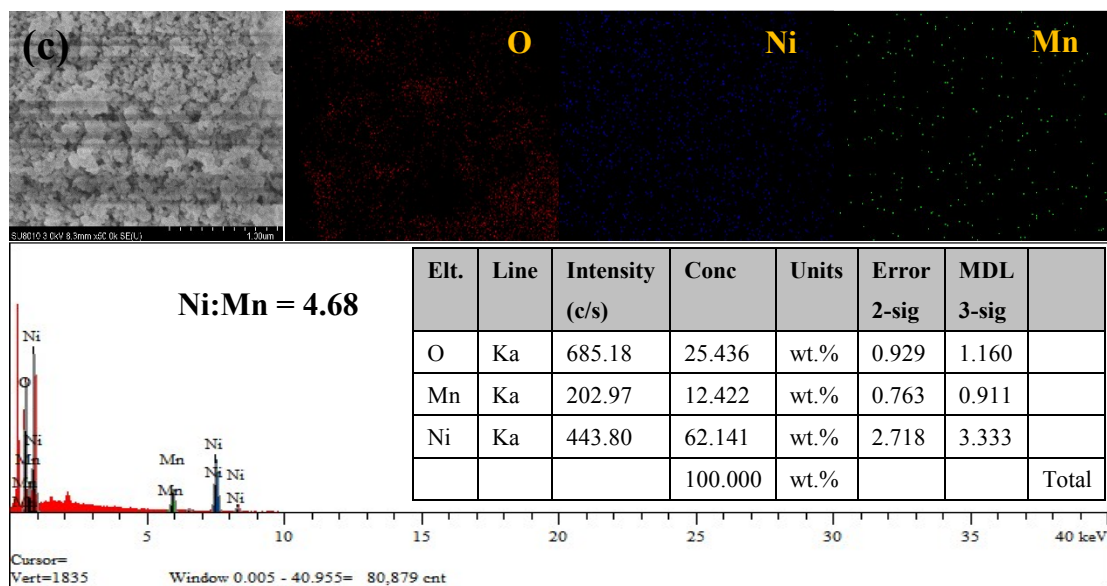


Fig. S3 SEM image and EDS mapping of Ni₅Mn-LDO catalyst.

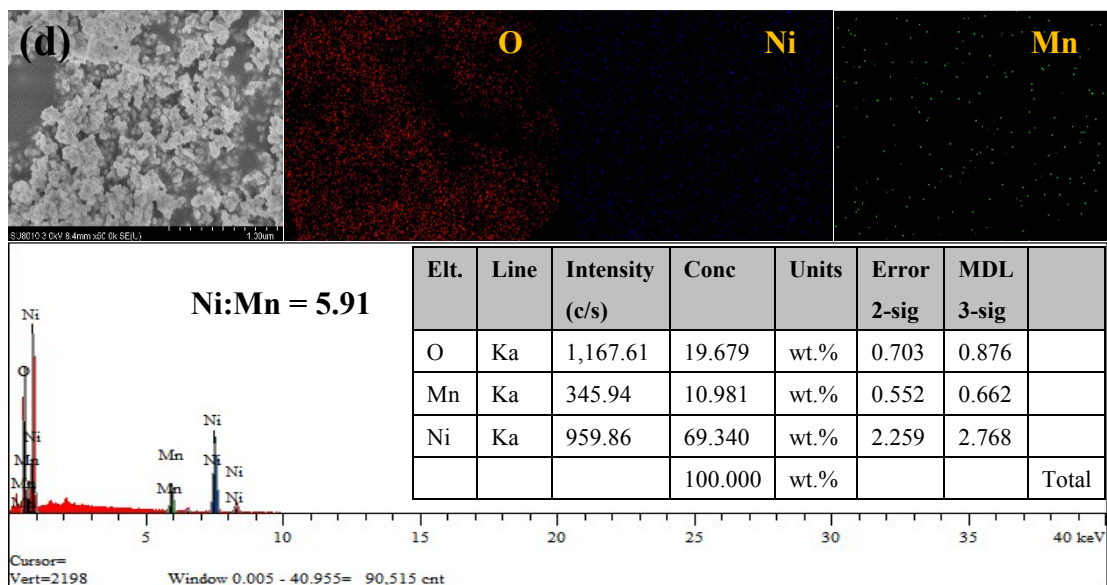


Fig. S4 SEM image and EDS mapping of Ni₆Mn-LDO catalyst.

Notes and references

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